

DPW

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Inventor Application of:
DINESH CHOPRA

Serial No.: 10/681,926

Filed: October 9, 2003

For: METHOD OF REDUCING OXIDATION
OF METAL STRUCTURES BY
SELECTIVELY IMPLANTING IONS
THROUGH A MASK POSITIONED
ABOVE AND NOT IN CONTACT WITH
THE SUBSTRATE (as amended)

Group Art Unit: 2813

Examiner: Thanh T. Nguyen

Atty. Dkt. No.: 2008.006382

Customer No.: 23720

RESPONSE TO OFFICE ACTION DATED OCTOBER 15, 2004

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING 37 C.F.R. 1.8	
I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:	
January 18, 2005 Date	<i>May Paul</i> Signature

This paper is submitted in response to the Office Action dated October 15, 2004, for which the three-month date for response was January 15, 2005. A request for a one-month extension of time to respond is included herewith along with the required fee. This one-month extension will bring the due date to February 15, 2005, which is within the six-month statutory period.

A check in the amount of \$250.00 is enclosed to cover the fees believed to be due in connection with the present paper. If the check is missing or insufficient, the Director is authorized to deduct such fee, and any other fees required under 37 C.F.R. §§ 1.16 to 1.21, from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2008.006300.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.

01/25/2005 SFELEKE1 00000048 10681926

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